	LATER AT ALL	
	Application No.	Applicant(s)
Notice of Allowability	10/807,770	WHITE, NICHOLAS R.
	Examiner	Art Unit
	Nikita Wells	2881
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31	(OR REMAINS) CLOSED in the community of	this application. If not included nication will be mailed in due course. THIS
1. X This communication is responsive to Examiner's Amendm	ent and Application filed 24 M	arch 2004.
2. X The allowed claim(s) is/are <u>1-11</u> .		
3. The drawings filed on are accepted by the Examine	er.	
4. Acknowledgment is made of a claim for foreign priority u a) All b) Some* c) None of the: 1. Certified copies of the priority documents hav 2. Certified copies of the priority documents hav 3. Copies of the certified copies of the priority documents hav International Bureau (PCT Rule 17.2(a)).	e been received. e been received in Application	No
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDON! THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		a reply complying with the requirements
5. A SUBSTITUTE OATH OR DECLARATION must be submineformal patent application (PTO-152) which give		
6. 🗵 CORRECTED DRAWINGS (as "replacement sheets") mu	st be submitted.	
(a) including changes required by the Notice of Draftsper	son's Patent Drawing Review	(PTO-948) attached
1) 🗌 hereto or 2) 🗍 to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner Paper No./Mail Date <u>030405</u> .	's Amendment / Comment or i	n the Office action of
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	1.84(c)) should be written on the the header according to 37 CFR	e drawings in the front (not the back) of t 1.121(d).
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT 	osit of BIOLOGICAL MATE FOR THE DEPOSIT OF BIOI	RIAL must be submitted. Note the LOGICAL MATERIAL.
Attachment(s) 1. ⊠ Notice of References Cited (PTO-892)	5. □ Notice of Info	ormal Patent Application (PTO-152)
 Notice of References Cited (F10-692) Dotice of Draftperson's Patent Drawing Review (PT0-948) 		• • • • • • • • • • • • • • • • • • • •
	Paper No./N	Mail Date <u>030305</u> .
 Information Disclosure Statements (PTO-1449 or PTO/SB/ Paper No./Mail Date 	(08), 7. ⊠ Examiner's A	Amendment/Comment
4. Examiner's Comment Regarding Requirement for Deposit		Statement of Reasons for Allowance
of Biological Material	9. 🗌 Other	
		Nikita Wells Primary Examiner Art Unit: 2881

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DETAILED ACTION

Examiner's amendment (

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with David Prahker on March 4, 2005.

The Examiner initiated an interview with the Applicant in order to make minor changes in notation in the Specification and claims 2 and 11 in order to remove any possible confusion. The changes are as follows:

In the Specification, on page 8:

On line 16, "(Y)" has been changed to --(a)--.

On line 18, "(ύ)" has been changed to --(b)--.

In claim 2:

On line 16, "(Y)" has been changed to --(a)--.

On line 18, " (\dot{v}) " has been changed to --(b)--.

In claim 11:

On line 13, "(Y)" has been changed to --(a)--.

On line 15, "(ú)" has been changed to --(b)--.

Allowable Subject Matter

- 2. Claims 1-11 are allowed.
- 3, The following is an examiner's statement of reasons for allowance:

With respect to the independent claims 1, 2, 10, and 11, prior art fails to disclose or make obvious, in combination with other recited features of the claim limitations, an ion implantation apparatus and method including a source for the generation of charged particles as a continuous ion beam irradiating a workpiece; a multiplole coil array comprised of a support rod made of ferromagnetic material and at least two wire coils wound independently and positioned adjacently on said support rod, being wound to lie orthogonally to said support bar; a boundary plate presenting a planar surface which is positioned to lie parallel to and at a preset gap distance from said multipole coil array; and a circumscribed spatial passageway for applying a contiguous magnetic field having a customized magnetic field gradient to a continuous ion beam traveling therethrough, wherein said spatial passageway is dimensionally circumscribed in an x-axis direction by the length of said multipole coil array and in a y-axis direction by a preset gap distance separating said multipole array from said plane surface of said boundary plate, and wherein the degree of uniformity for the charged particles of a continuous ion beam becomes increased.

The dependent claims 3-9, are allowable by virtue of their dependence upon the independent claims 1 and 2.

Drawings

4. New corrected formal drawings are required in this application because the submitted drawings are not numbered consecutively starting with Figure 1 as required in

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35 U.S.C. §1.84 (t). Figures A through E, 1A, and 1B, should be relabeled as 1, 2, 3, 4, 5, etc. The corrected drawings are required in reply to the Office action to avoid abandonment of the application. The requirement for corrected drawings will not be held in abeyance.

Conclusion

- 5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Benveniste et al. (6,835,930 B2), V.M. Benveniste (2003/0205683 A1), and Ye et al. (6,703,628 B2) disclose an ion implantation system using a ribbon ion beam which is mass analyzed and collimated for use in implanting one or more workpieces. H.F. Glavish (5,483,077) discloses a system and method for magnetic scanning, accelerating, and implanting a ribbon ion beam.
- 6. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."
- 7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nikita Wells whose telephone number is (571) 272-2484. The examiner can normally be reached on 8:30 AM 5:00 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John R. Lee can be reached on (571) 272-2477. The central fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.
- 8. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for

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published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Nikita Wells, Primary Examiner

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